

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

5/28/03  
#5(election)

In re Application of:

Arpan P. Mahorowala et al.

Serial No.: 09/902,728

Filed: July 12, 2001



Examiner: Barreca, Nicole M.

Art Unit: 1756

Atty Docket: YOR920000789US1

RECEIVED  
MAY 22 2003  
GROUP 1700

For: METHOD TO PREVENT PATTERN COLLAPSE IN FEATURES ETCHED IN  
SULFUR DIOXIDE-CONTAINING PLASMAS

**RESPONSE TO RESTRICTION REQUIREMENT**

Commissioner for Patents  
P. O. Box 1450  
Alexandria 22313-1450

Sir:

In response to the Restriction Requirement dated April 7, 2003, Applicant elects Group I, drawn to a method classified in Class 430, subclass 322. Claims 1-17 and 20-21 are readable on the elected Group.

If the Examiner believes that an interview would facilitate the prosecution of this case, Applicants urge the Examiner to contact the undersigned at the telephone number listed below.

The undersigned hereby authorizes the Commissioner to charge any insufficient fees or credit any overpayment associated with this communication to Deposit Account No. 22-0185.

Respectfully submitted,

Date: May 15, 2003

7755\_1

John A. Evans, Reg. No. 44,100  
Attorney for Applicants  
Connolly Bove Lodge & Hutz LLP  
1990 M Street, N.W.  
Washington, DC 20036-3425  
Telephone: 202-331-7111  
Facsimile: 202-293-6229